

2. (Amended) The method according to claim 1, the defining a coating area step including defining the coating area to include the perimeter of the effectively optical area.

3. (Amended) The method according to claim 1, the defining a coating area step including defining the coating area located along the perimeter of the effectively optical area to be a dummy area in which the composition including the organic EL material is also coated to form an organic EL layer.

4. (Amended) The method according to claim 3, further comprising:
forming a layer made of the same material as that of the electrodes in the dummy area; and

coating the composition including the organic EL material on the layer.

5. (Amended) The method according to claim 1, further comprising:
providing a group of effectively optical areas formed of a plurality of the effectively optical areas on a substrate; and

defining dummy areas around the effectively optical areas, respectively, and another dummy area encompassing the group of effectively optical areas.

6. (Amended) The method according to claim 3, further including starting the step of coating the composition including the organic EL material at the dummy area prior to coating on the effectively optical area and ending at the dummy area after coating on the effectively optical area.

7. (Amended) The method according to claim 1, further including disposing individual areas to be coated in the entirety of the coating area at a constant pitch from each other.

8. (Amended) The method according to claim 7, further including disposing any one of the electrodes relative to adjacent ones of the electrodes at a constant pitch.

9. (Amended) A method for manufacturing an organic EL device which includes an effectively optical area having a plurality of electrodes and an organic EL layer formed above each of the plurality of electrodes, the method comprising:

forming the organic EL layer both on areas that are to be the effectively optical area and on other areas that are not to be the effectively optical area.

10. (Amended) A method for manufacturing an organic EL device which includes an effectively optical area having a plurality of electrodes and an organic EL layer formed above each of the plurality of electrodes, the method comprising:

forming the organic EL layer in areas not having the electrodes and which are supposed to be the effectively optical area.

11. (Amended) An organic EL device manufactured according to the method of claim 1.

12. (Amended) An organic EL device, comprising:
a plurality of electrodes;

an organic EL layer formed above each of the plurality of electrodes;

an effectively optical area in which the plurality of electrodes are formed; and

a dummy area, that is disposed around the effectively optical area, in which the electrodes are also formed.

13. (Amended) The organic EL device according to claim 12, further comprising a bank layer disposed between the plurality of electrodes, the organic EL layer in the dummy area being disposed on a layer made of a same material as the bank layer.

14. (Amended) The organic EL device according to claim 13, the bank layer including an organic bank layer and an inorganic bank layer, and the organic EL layer in the dummy area being disposed on a layer made of a same material as the inorganic bank layer.

15. (Amended) The organic EL device according to claim 14, the bank layer being disposed laterally between portions of the organic EL layer in the dummy area.

16. (Amended) The organic EL device according to claim 13, the organic EL layer in the dummy area being disposed on a layer made of a same material as the organic bank layer.

17. (Amended) The organic EL device according to claim 12, the organic EL layer in the dummy area being disposed on a layer made of a same material as the electrodes.

18. (Amended) The organic EL device according to claim 17, the bank layer being formed laterally between portions of the organic EL layer in the dummy area.

19. (Amended) The organic EL device according to claim 12, adjacent portions of the organic EL layer being disposed at a constant pitch in both the effectively optical area and the dummy area.

20. (Amended) The organic EL device according to claim 12, both the effectively optical area and the dummy area being provided on a substrate, and portions in the effectively optical area on the substrate having a substantially same cross-sectional structure as portions in the dummy area on the substrate.

21. (Amended) An organic EL device, comprising:
an effectively optical area having a plurality of electrodes and an organic EL layer formed on each of the plurality of electrodes, the organic EL layer being formed both on areas supposed to be the effectively optical area and on other areas not supposed to be the effectively optical area.

22. (Amended) An organic EL device, comprising:
an effectively optical area having a plurality of electrodes and an organic EL layer formed above each of the electrodes, the organic EL layer being formed in areas not having the electrodes and which are supposed to be the effectively optical area.

23. (Twice Amended) An electronic device, comprising:
the organic EL device according to claim 12.